

Tres-Ark Liquid Dispense Module PLUS

PRODUCT DESCRIPTION

FractalFill™ Blending Products are turn-key solutions for implementing real-time closed loop control and dispense of multi-variant chemical mixes to meet exacting requirements in advanced semiconductor wafer cleaning and etching processes. The Tres-Ark Liquid Dispense Module PLUS, or the TAKLDM+, supplies multiple tools with a single chemical solution. In addition to achieving Angstrom-level etch control, the TAKLDM+ eliminates module-to-module chemical variability and offers a smaller footprint as it solves all of your blending and delivery needs.

FACILITY REQUIREMENTS

Power -	208 - 240 vac single phase 2 amp
CDA -	24 SCFM at 100 psig
N2 -	15 psi, 1/4", 0.2 lpm
DIW -	55 - 60 psi, 1/2", 20 lpm
Chemicals (2) -	30 60 pst: 1/4", 1-3 lpm
Exhaust -	100 scfm: 4" connection
Drain -	3/4" connection
Delivery Flow Rate -	12 lpm

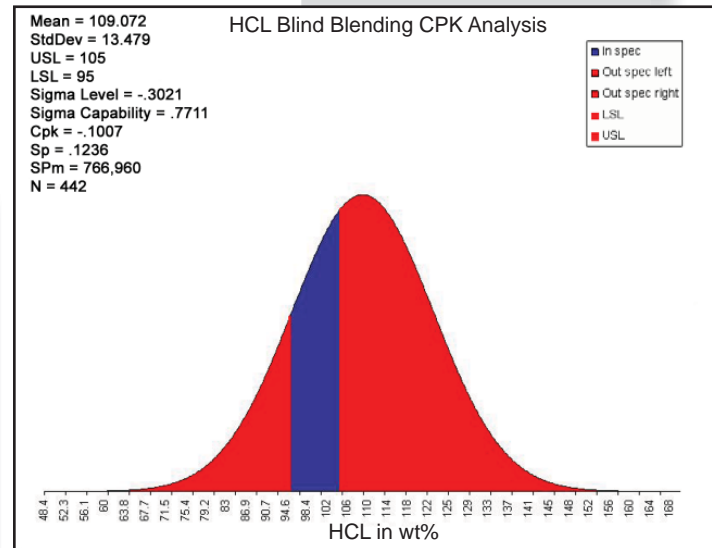
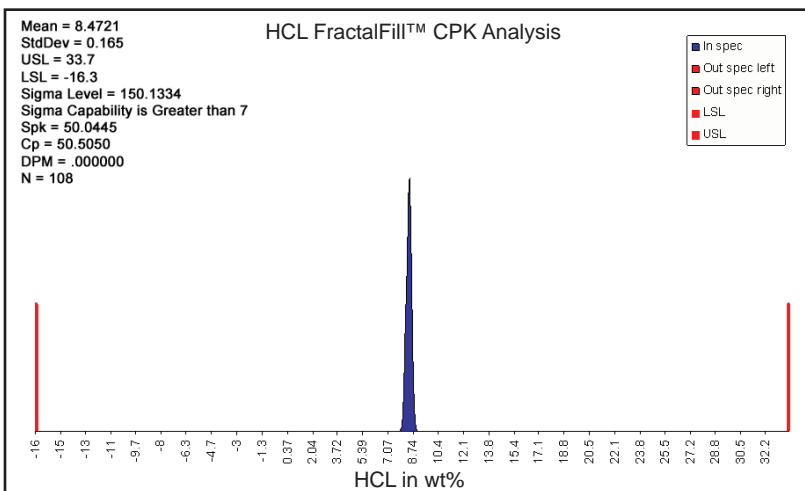
Contact for customization questions



depth - 31"
width - 34"
height - 63.43"

The semiconductor industry's best blending data

FRACTALFILL™ BLENDING DATA



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